

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Application No.:

09/744,877

Filing Date:

January 29, 2001

Inventor(s):

Halimaoui et al.

Title: PROCESS FOR FORMING

AN OXIDE LAYER OF NON-

UNIFORM THICKNESS ON

THE SURFACE OF A SILICON SUBSTRATE

Examiner: §

Novacek, Christy

Group/Art Unit: 2822

Atty. Dkt. No:

5310-03000

CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8

DATE OF DEPOSIT:

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail on the date indicated above and is addressed to:

Commissioner for Patents P.O. Box 1450

Alexandria, VA

AMENDMENT; RESPONSE TO OFFICE ACTION MAILED FEBRUARY 27, 2003

Mail Stop Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Amendment

Sir:

Please amend the above-captioned application as follows: